## Amendments to the Claims:

This listing of claims will replace all prior versions and listings of claims in the application.

### Listing of Claims:

- 1-64. (Cancelled)
- 65. (Currently amended) The Josephson junction device of claim 59A

  Josephson junction device, comprising:

a first layer comprising an oxide high-temperature superconductor;

a second layer comprising an oxide high-temperature superconductor; and

a third layer connecting the first and second layers and comprising a non-

# superconductor,

the first and third layers being formed from a starting oxide high-temperature superconductor layer of an oxide high-temperature superconductor, the third layer being an ion-modified portion of the starting oxide high-temperature superconductor layer, the first layer being an unmodified portion of the starting oxide high-temperature superconductor layer.

the device having an  $R_nA$  value of about  $1\times10^{-9}$  to about  $3\times10^{-7}$   $\Omega$ -cm<sup>2</sup> at 4.2 K.

- 66. (Currently amended) The Josephson junction device of claim 65[2], wherein the first layer comprises an YBCO superconducting oxide-having an R<sub>w</sub>A value of about 1×10<sup>-9</sup> to about 3×10<sup>-7</sup>.0-cm<sup>2</sup> at 4.2K.
- 67. (Currently amended) The device of claim 1 An electronic device comprising:

a crystalline substrate;

an electrode formed on and epitaxial to the substrate, the electrode comprising a first superconductive oxide;

a barrier comprising a non-superconducting, ion-modified surface layer of the first superconductive oxide; and

a counter-electrode formed directly on and epitaxial to the barrier, the counter-electrode comprising a second superconductive oxide, whereby a Josephson junction is formed between the electrode and the counter-electrode, having an  $R_nA$  value of about  $1\times10^{-9}$  to about  $3\times10^{-7}\,\Omega$ -cm<sup>2</sup> at  $4.2\,K$ .

68. (Currently amended) The device of claim 67, wherein the first and second superconductive oxides are YBCO having an R<sub>n</sub>A value of about 1×10<sup>-9</sup> to about 3×10<sup>-7</sup> Q-cm<sup>2</sup> at 4.2K.

### 69. (Cancelled)

#### 70. (Cancelled)

71. (Currently amended) The Josephson junction device of claim 59A

Josephson junction device, comprising:

a first layer comprising an oxide high-temperature superconductor;

a second layer comprising an oxide high-temperature superconductor; and a third layer connecting the first and second layers and comprising a nonsuperconductor,

the first and third layers being formed from a starting oxide high-temperature superconductor layer of an oxide high-temperature superconductor, the third layer being an ion-modified portion of the starting oxide high-temperature superconductor layer, the first layer being an unmodified portion of the starting oxide high-temperature superconductor layer,

the device having a  $J_c$  value of about  $1\times10^3$  to about  $5\times10^6$  A/cm² at 4.2\_K.

72. (Currently amended) The Josephson junction device of claim 7162 wherein the first layer comprises an YBCO superconducting oxide, having a J<sub>e</sub>-value of about 1×10<sup>2</sup> to about 5×10<sup>6</sup> A/em<sup>2</sup> at 4.2K.

73. (Currently amended) The Josephson junction device of claim 1An electronic device comprising:

a crystalline substrate;

an electrode formed on and epitaxial to the substrate, the electrode comprising a first superconductive oxide;

a barrier comprising a non-superconducting, ion-modified surface layer of the first superconductive oxide; and

a counter-electrode formed directly on and epitaxial to the barrier, the counterelectrode comprising a second superconductive oxide, whereby a Josephson junction is formed between the electrode and the counter-electrode.

the device having a  $J_c$  value of about  $1\times10^3$  to about  $5\times10^6~\text{A/cm}^2$  at  $4.2\text{\_K}.$ 

- 74. (Currently amended) The Josephson junction device of claim 73[7],

  wherein the first and second superconductive oxides are YBCOhaving a J<sub>e</sub> value of about

  1×10<sup>2</sup> to about 5×10<sup>6</sup> A/em<sup>2</sup> at 4.2K.
- 75. (New) The Josephson junction device of claim 65, wherein the third layer is substantially uniform.